

Response Etch rate [nm/min]

Effect Summary

Source	LogWorth	PValue
Power(60,160)	13,446	0,00000
Pressure(66,94)	2,787	0,00163
CHF3/CF4(1,2,6)	1,972	0,01066
Total flow(100,136)	0,929	0,11772

Prediction Profiler

